	Application No.	Applicant(s)	
N. 4 of Allowahility	09/966,080	KAMIJIMA ET AL.	
Notice of Allowability	Examiner	Art Unit	
	John Ruggles	1756	
The MAILING DATE of this communication All claims being allowable, PROSECUTION ON THE MERIT herewith (or previously mailed), a Notice of Allowance (PTOI NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATEN of the Office or upon petition by the applicant. See 37 CFR	S IS (OR REMAINS) CLOSED in 85) or other appropriate commeter application is application is application.	n this application. If not included unication will be mailed in due cours	ie. <b>THIS</b> he initiative
1.   This communication is responsive to the amendment	filed on 12 November 2004.	·	
2. ⊠ The allowed claim(s) is/are <u>1,2 and 4-47</u> .			
3. The drawings filed on are accepted by the Exa	miner.		
4.	have been received.  have been received in Application to describe the documents have been received at a communication to file and the communication to file	on No  d in this national stage application for the areply complying with the requirer AMINER'S AMENDMENT or NOTIC or declaration is deficient.  W ( PTO-948) attached  r in the Office action of the drawings in the front (not the backer 1.121(d).  ERIAL must be submitted. Note the	ments CE OF
Attachment(s)			
1. ⊠ Notice of References Cited (PTO-892)	<del></del>	formal Patent Application (PTO-152	<b>?)</b>
2. Notice of Draftperson's Patent Drawing Review (PTO-S	Paper No.	ummary (PTO-413), /Mail Date	
Information Disclosure Statements (PTO-1449 or PTO- Paper No./Mail Date		Amendment/Comment	
4. Examiner's Comment Regarding Requirement for Dep		Statement of Reasons for Allowand	
of Biological Material	9. ☐ Other	John Ruggles Examiner, Art Unit 1756 571-272-1390	-

## **DETAILED ACTION**

## **Drawings**

The drawings are objected to as failing to comply with 37 CFR 1.84(p)(4) because reference character "27" has been used to designate both the resist pattern in Figure 14 and the patterned thin film in Figure 15 (the patterned thin film is --29-- in paragraph [0054] line 5 of the specification, rather than "27" as shown in Figure 15). Corrected drawing sheets in compliance with 37 CFR 1.121(d) are required in reply to the Office action to avoid abandonment of the application. Any amended replacement drawing sheet should include all of the figures appearing on the immediate prior version of the sheet, even if only one figure is being amended. The replacement sheet(s) should be labeled "Replacement Sheet" in the page header (as per 37 CFR 1.84(c)) so as not to obstruct any portion of the drawing figures. If the changes are not accepted by the examiner, the applicant will be notified and informed of any required corrective action in the next Office action. The objection to the drawings will not be held in abeyance.

## Allowable Subject Matter

Claims 1-2 and 4-47 are allowed.

The following is an examiner's statement of reasons for allowance: Okoroanyanwu et al. (US Patent 6,653,231) in combination with the previously cited art references clearly teaches (1) narrowing of a developed resist pattern by subsequent hardening as shown in Figures 4A-4C and then trimming of the resist pattern to sub-lithographic critical dimensions as shown in Figure 5 (abstract, reading on the instant narrowing of a resist pattern below an optically theoretical limitation) and (2) cross-linking of at least surface portions of a developed resist pattern before

Application/Control Number: 09/966,080

Art Unit: 1756

trimming to narrow the developed resist pattern, in order to increase the interfacial toughness of the substrate-resist polymer bond (i.e. the bond between feature 50 (the hardened resist pattern before trimming) and layer 28 (directly underlying the resist), as shown in Figures 4A-4C, column 6 lines 23-30). However, none of the prior art searched specifically teaches *increasing* bond strength between the pre-resist pattern and a base material by increasing an amount of relative contact area of the pre-resist pattern and the base material by ash-treating the pre-resist pattern (emphasis added), as now recited by instant claims 1, 14, 17, 21, 24, 27, 31, 34, 37, 41, and 47.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

## Conclusion

This application is in condition for allowance except for the objections to the drawings, as set forth above.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to John Ruggles whose telephone number is 571-272-1390. The examiner can normally be reached on Monday-Thursday and alternate Fridays.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Mark Huff can be reached on 571-272-1385. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Application/Control Number: 09/966,080 Page 4

Art Unit: 1756

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Examiner
Art Unit 1756

MARK F. HUFF/ CUDEDVICORY PATENT EXAMINER

TECHNOLOGY CENTER 1700